

L Number	Hits	Search Text	DB	Time stamp
1	100	drift\$3 near zone	USPAT	2003/09/24 09:34
2	12	(drift\$3 near zone) and plasma	USPAT	2003/09/24 09:17
3	280	drift\$3 near3 zone	USPAT	2003/09/24 09:38
4	32	(drift\$3 near3 zone) and plasma	USPAT	2003/09/24 09:35
5	20	((drift\$3 near3 zone) and plasma) not	USPAT	2003/09/24 09:35
6	1626	((drift\$3 near zone) and plasma) drift\$3 with (magnetic or magnet or magnetization or magnetize)	USPAT	2003/09/24 09:39
7	544	(drift\$3 with (magnetic or magnet or magnetization or magnetize)) and (plasma or ICP)	USPAT	2003/09/24 09:38
8	209	((drift\$3 with (magnetic or magnet or magnetization or magnetize)) and (plasma or ICP)) and (etch or etching)	USPAT	2003/09/24 09:39
9	41	((((drift\$3 with (magnetic or magnet or magnetization or magnetize)) and (plasma or ICP)) and (etch or etching)) and (inductive or inductively or ICP)	USPAT	2003/09/24 09:39
10	227	((((ICP or (inductive\$2 adj couple\$1 adj plasma)) and coil) and 156/345.\$2.ccls.) not ((((((ICP or (inductive\$2 adj couple\$1 adj plasma)) and coil) and (magnetic near4 coil)) and (semiconductor or silicon)) and @ay<=2000) and (magnetic adj2 coil)) or (((ICP or (inductive\$2 adj couple\$1 adj plasma)) and coil) and 156/345.33.ccls.))	USPAT	2003/09/24 10:39
-	1387	(ICP or (inductive\$2 adj couple\$1 adj plasma)) and coil	USPAT	2003/05/30 12:08
-	779	((ICP or (inductive\$2 adj couple\$1 adj plasma)) and coil) and magnetic	USPAT	2003/05/30 15:37
-	334	((ICP or (inductive\$2 adj couple\$1 adj plasma)) and coil) and (magnetic near4 coil)	USPAT	2003/05/30 11:48
-	276	((((ICP or (inductive\$2 adj couple\$1 adj plasma)) and coil) and (magnetic near4 coil)) and (semiconductor or silicon))	USPAT	2003/05/30 11:49
-	252	(((((ICP or (inductive\$2 adj couple\$1 adj plasma)) and coil) and (magnetic near4 coil)) and (semiconductor or silicon)) and @ay<=2000	USPAT	2003/05/30 11:50
-	75	(((((ICP or (inductive\$2 adj couple\$1 adj plasma)) and coil) and (magnetic near4 coil)) and (semiconductor or silicon)) and @ay<=2000) and (magnetic adj2 coil)	USPAT	2003/09/24 09:17
-	14	((ICP or (inductive\$2 adj couple\$1 adj plasma)) and coil) and 156/345.33.ccls.	USPAT	2003/05/30 12:11
-	0	((ICP or (inductive\$2 adj couple\$1 adj plasma)) and coil) and 156/345.ccls.	USPAT	2003/05/30 12:11
-	263	((ICP or (inductive\$2 adj couple\$1 adj plasma)) and coil) and 156/345.\$2.ccls.	USPAT	2003/05/30 15:07
-	220	((((ICP or (inductive\$2 adj couple\$1 adj plasma)) and coil) and 156/345.\$2.ccls.) not ((((((ICP or (inductive\$2 adj couple\$1 adj plasma)) and coil) and (magnetic near4 coil)) and (semiconductor or silicon)) and @ay<=2000) and (magnetic adj2 coil)) or (((ICP or (inductive\$2 adj couple\$1 adj plasma)) and coil) and 156/345.33.ccls.))	USPAT	2003/09/24 10:39
-	1	6471822.pn.	USPAT	2003/05/30 15:04
-	1	6189484.pn.	USPAT	2003/05/30 14:12

-	1	6247425.pn.	USPAT	2003/05/30 15:04
-	172	(((((ICP or (inductive\$2 adj couple\$1 adj plasma)) and coil) and 156/345.\$2.ccls.) not ((((((ICP or (inductive\$2 adj couple\$1 adj plasma)) and coil) and (magnetic near4 coil)) and (semiconductor or silicon)) and @ay<=2000) and (magnetic adj2 coil)) or (((ICP or (inductive\$2 adj couple\$1 adj plasma)) and coil) and 156/345.33.ccls.))) and current	USPAT	2003/05/30 15:08
-	30	(((((ICP or (inductive\$2 adj couple\$1 adj plasma)) and coil) and 156/345.\$2.ccls.) not ((((((ICP or (inductive\$2 adj couple\$1 adj plasma)) and coil) and (magnetic near4 coil)) and (semiconductor or silicon)) and @ay<=2000) and (magnetic adj2 coil)) or (((ICP or (inductive\$2 adj couple\$1 adj plasma)) and coil) and 156/345.33.ccls.))) and (current with direction)	USPAT	2003/05/30 16:20
-	30	(((((ICP or (inductive\$2 adj couple\$1 adj plasma)) and coil) and (magnetic near4 coil)) and (semiconductor or silicon)) and @ay<=2000) and (magnetic adj2 coil)) and (current with direction)	USPAT	2003/05/30 15:15
-	30	(((((ICP or (inductive\$2 adj couple\$1 adj plasma)) and coil) and (magnetic near4 coil)) and (semiconductor or silicon)) and @ay<=2000) and (magnetic adj2 coil)) and (current with direction)) not (((ICP or (inductive\$2 adj couple\$1 adj plasma)) and coil) and 156/345.\$2.ccls.) not ((((((ICP or (inductive\$2 adj couple\$1 adj plasma)) and coil) and (magnetic near4 coil)) and (semiconductor or silicon)) and @ay<=2000) and (magnetic adj2 coil)) or (((ICP or (inductive\$2 adj couple\$1 adj plasma)) and coil) and 156/345.33.ccls.))) and (current with direction))	USPAT	2003/05/30 15:22
-	28	(((((ICP or (inductive\$2 adj couple\$1 adj plasma)) and coil) and (magnetic near4 coil)) and (semiconductor or silicon)) and @ay<=2000) and spacer	USPAT	2003/05/30 15:22
-	86	((ICP or (inductive\$2 adj couple\$1 adj plasma)) and coil) and magnetic) and spacer	USPAT	2003/05/30 15:33
-	58	((ICP or (inductive\$2 adj couple\$1 adj plasma)) and coil) and magnetic) and spacer) not ((((((ICP or (inductive\$2 adj couple\$1 adj plasma)) and coil) and (magnetic near4 coil)) and (semiconductor or silicon)) and @ay<=2000) and spacer)	USPAT	2003/05/30 15:33
-	20	((ICP or (inductive\$2 adj couple\$1 adj plasma)) and coil) and magnetic) and (spacer same coil)	USPAT	2003/05/30 16:00
-	1	6189484.pn.	USPAT	2003/05/30 16:00
-	1	6333269.pn.	USPAT	2003/05/30 16:29
-	1	6333269.pn. and current	USPAT	2003/05/30 16:29